


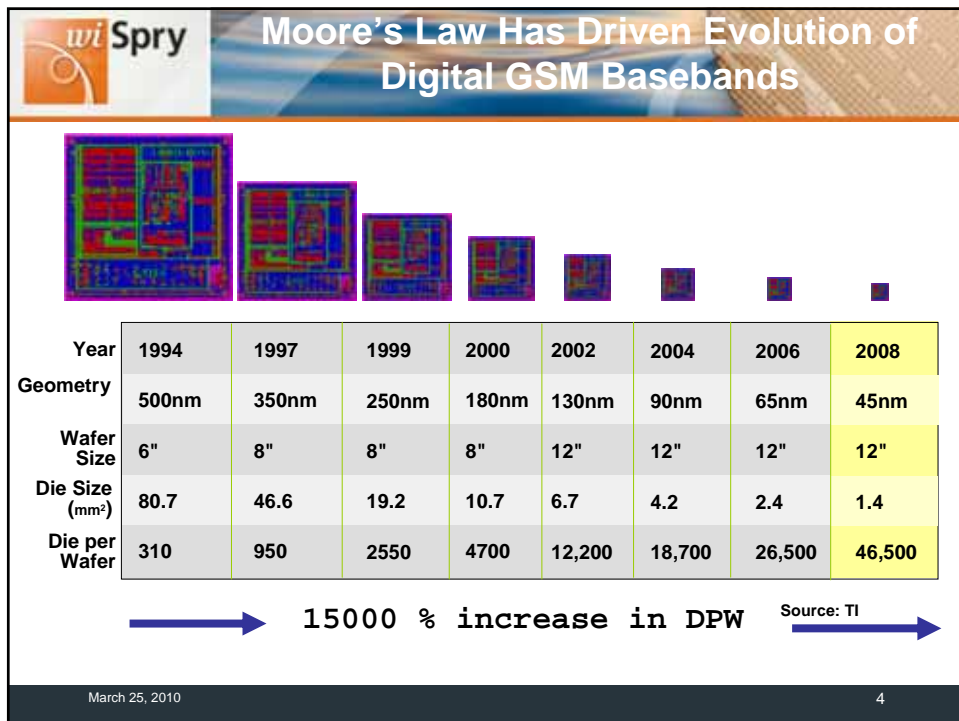
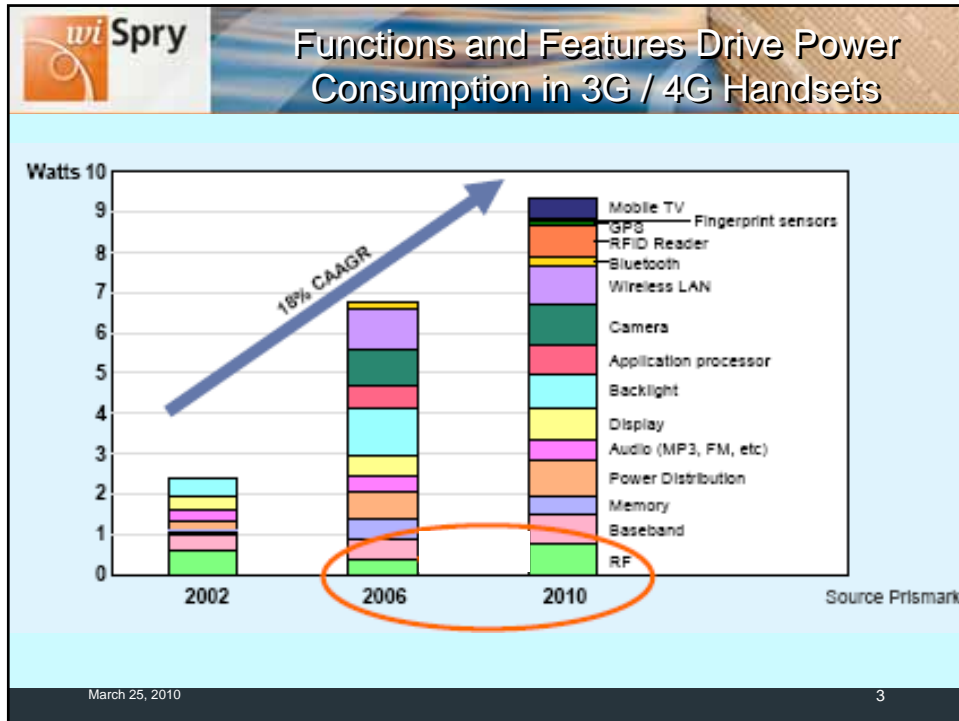



Integrated RF-CMOS MEMS Solutions for Mobile Terminals



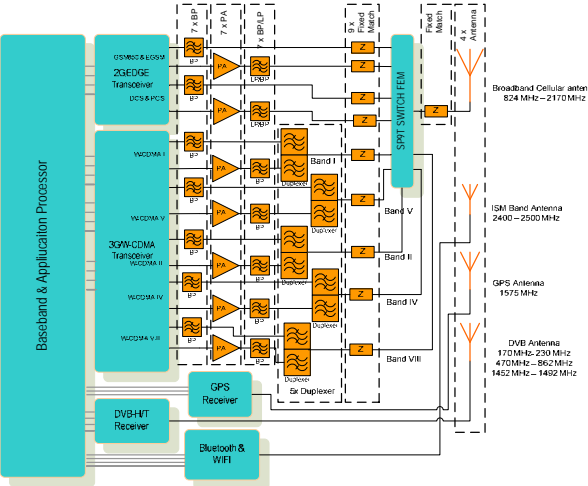
Jeffrey L. Hilbert, President, COO & Founder March 25, 2010








But Point Solutions Have Limited RF Integration



- ❖ **Compromised RF Performance**
 - Proliferation of Bands and Standards
 - Introduction of Multiple Antennas
- ❖ **Platform Design Cycle Too Long**
 - Hand Tuning of Platforms Required
 - Every Platform is a "Custom"
- ❖ **Increased Number of RF Paths**
 - Un-integratable "Point" Solutions
 - BOM Cost , Area, Power

Growing Number of Specialized, Static and Expensive RF Components
... And it only gets more difficult with 4G

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Removing RF Integration Limits

- Dynamically Reconfigure Properties / Performance of RF Functions Using Software
- Tunable, Re-Configurable, or Programmable RF Components
- Approaches Include
 - Switching
 - Modifying Material Properties
 - *Moving Micro-Scale Structures (RF-MEMS)*

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wiSpry RF-MEMS Enabled Tunable Components


- **High Value Solution to Pressing Problem, But**
 - Market Forces Make Adoption of New Disruptive Technology-Based Solutions Risky
 - Little to No High Volume Manufacturing and Field Performance Data to Demonstrate Production Readiness
- **Minimizing the Risk**
 - Thoughtful Selection of Customers and Initial Insertion Opportunities
 - Few to No Changes Required to Existing Customer Designs
 - Deep Integration with Mainstream CMOS Technology
 - Technology Platform Enabling High Level of Proven Silicon Design Re-Use
 - Early Demonstration of Insertion Readiness, Manufacturability, Scalability, and Reliability
 - “MEMS on the Inside”

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wiSpry Silicon MEMS (On Top) Fabrication Process
(0.18um, 3/50V RF-CMOS Process; 8" Wafers)

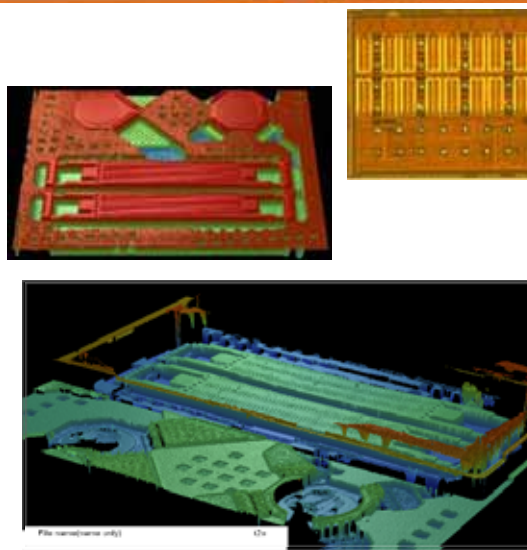
The diagram illustrates the cross-sectional structure of the Silicon MEMS (On Top) Fabrication Process. It shows a multi-layered structure with various components labeled. The top layer is a Pad, followed by a Thin-film wafer-level seal. Below this is the MEMS beam, which is connected to the MEMS Interconnect. The CMOS Interconnect is shown below the MEMS Interconnect, and the HVC MOS IC is located at the bottom. The micrograph below the diagram shows the physical structure of the MEMS beam, CMOS Interconnect, MEMS Interconnect, and HVC MOS IC, with a Thin-film wafer-level seal on top.

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Tunable (MEMS) Digital Capacitor (TDC)

- Ultra Low Power Single Chip Integration with Superior Measured RF Performance
 - Low Loss
 - Extreme Linearity (>>65dBm)
 - 10:1 Tune Range
 - High Power Handling (>40Vrms)
 - 100Vrms Longer-Term Goal
- Separate Signal and Control Paths
 - No Off-Chip Components Required
 - High Device Density
- Bit / Cell Architecture
 - Precise Two State Operation
 - Wide Range of Values Available
- Demonstrated Manufacturable and Reliable Structures

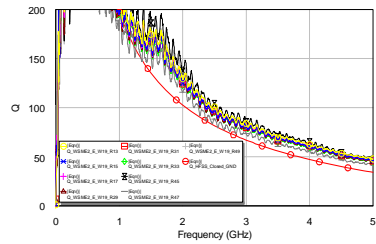


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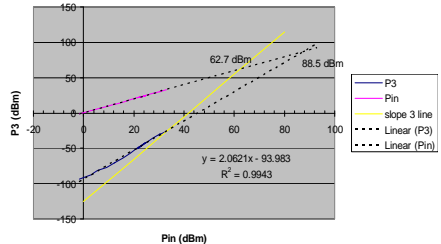


TDC Measured Data High Performance

Q > 100 @ 2 GHz for 1pF Cell

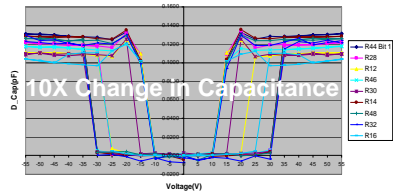


Ultra-Linear



High Capacitance Ratio

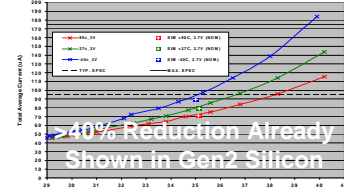
10X Change in Capacitance




Ultra-Low Power Consumption

Board #7 Supply Current vs. Regulated HV

40% Reduction Already Shown in Gen2 Silicon

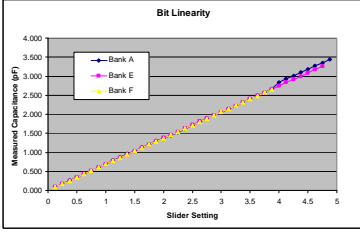


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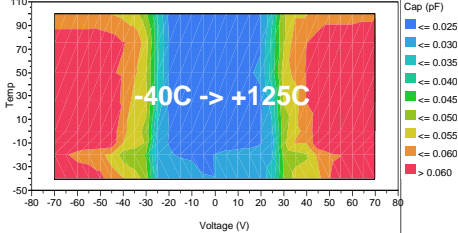


TDC Measured Data Highly Reliable and Robust


Excellent Bit Linearity



Temperature Stable

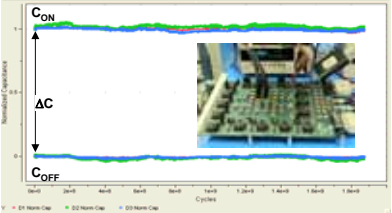


Hemeticity (Wafer-level Encapsulation)




Passes uHAST and
>96 Hours Autoclave

Long Life (> 1B Cycles in Parallel Testing)

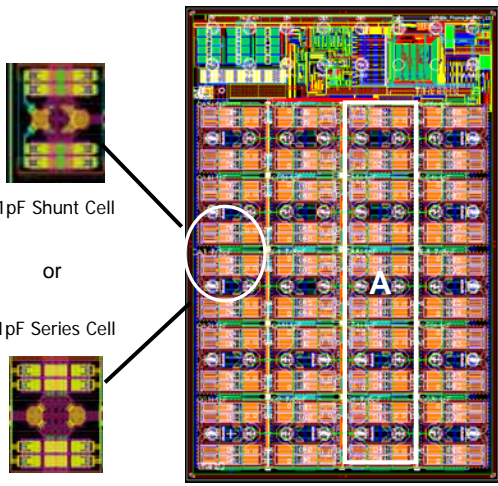


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Tunable (MEMS) Digital Capacitor Arrays (TDCA)

- Programmable Generic Capacitor Array Supporting Application-Specific Network Topologies
 - Variable Total Capacitance
 - Variable Step Size
 - Intermixing of Series and Shunt Devices
- True Single-Chip Solution Containing CMOS and MEMS



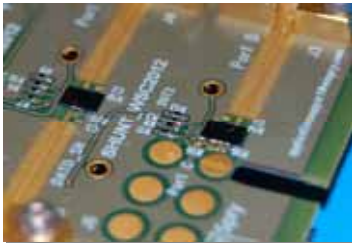
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WSC2012 Tunable Digital Capacitor Array (TDCA) with Serial Interface

Features:

- High-Q RF shunt and series capacitor array
- Network fully configurable by the user
- 12 pF total capacitance variation
- Precise digital control over 3 wire SPI interface
- Fully Integrated ultra low noise charge pump
- Low power sleep mode
- Excellent RF-performance with outstanding Q
- Network tuning time less than 100 us
- Delivered as bumped die version 3.8 mm x 2.5 mm
- Samples, datasheet, application note & ADS simulation package available




Applications:

- Dynamic antenna tuning
- Tunable amplifiers
- Programmable filters & tank circuits
- Antenna diversity and beam forming
- Frequency generation
- Programmable matching

The Evaluation Kit:


- Series and shunt with SMA connectors
- Flexible bank allocation
- ADS models
- Board can be battery powered
- Backside can be used for antenna tests
- Easy to use PC SW with interface



WSC2012 Evaluation Kit


The WSC2012 is a technology demonstration vehicle and is not yet a qualified product

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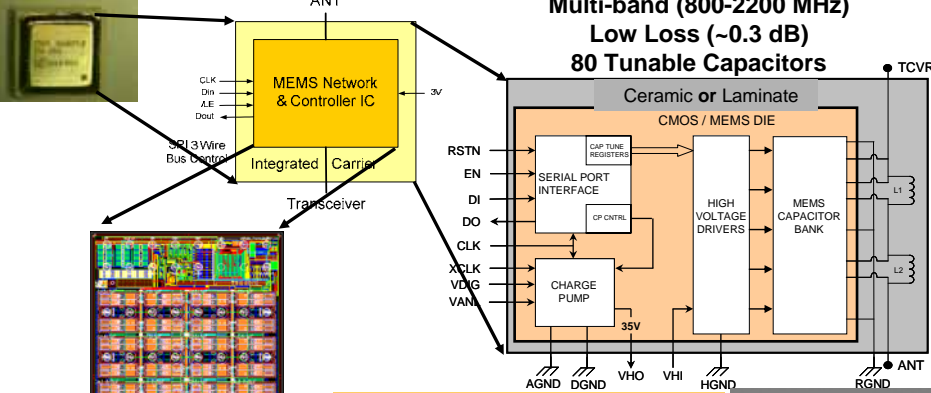


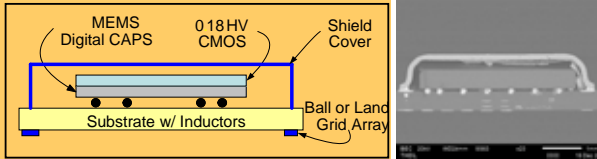
Example Application Tunable Impedance Matching (TIM) Network

**Multi-band (800-2200 MHz)
Low Loss (~0.3 dB)
80 Tunable Capacitors**

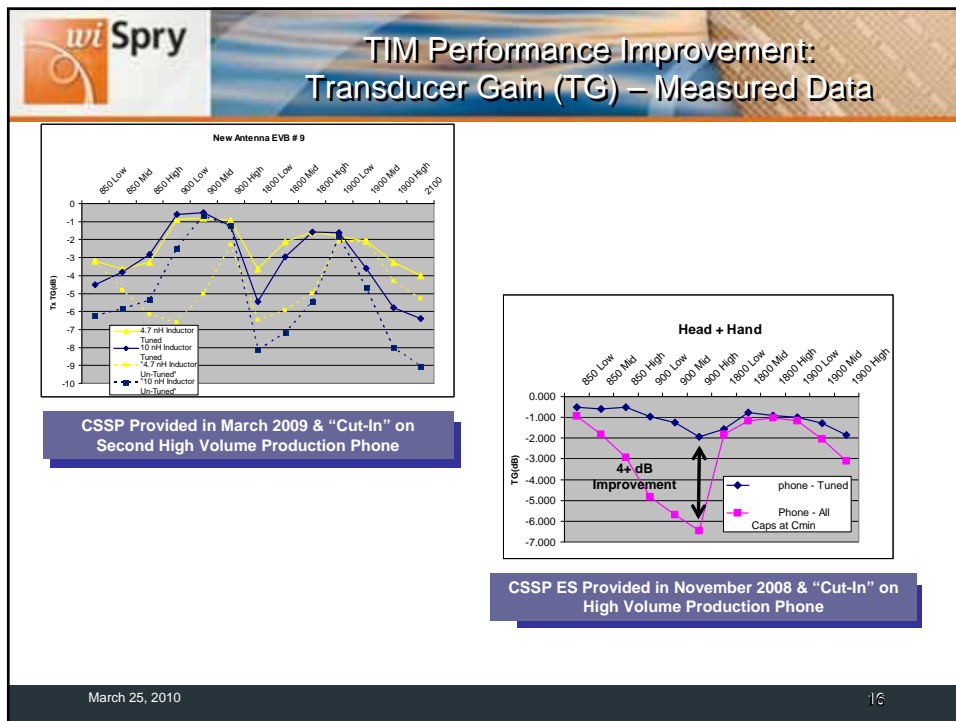
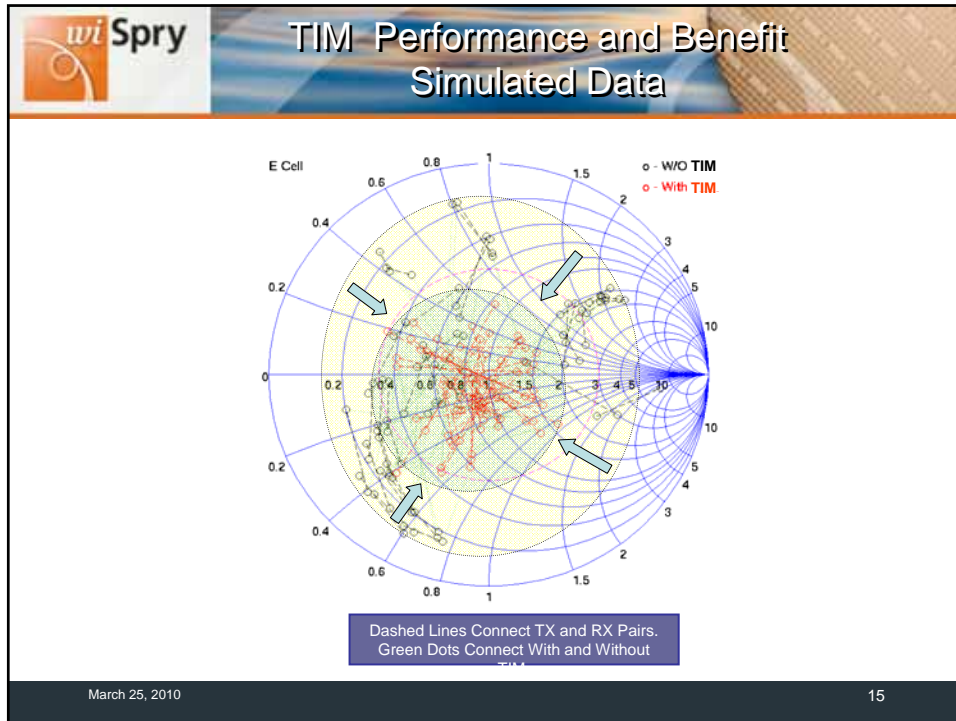



Tunable Caps, Drivers, Serial Port
Wafer Level Lid Seal






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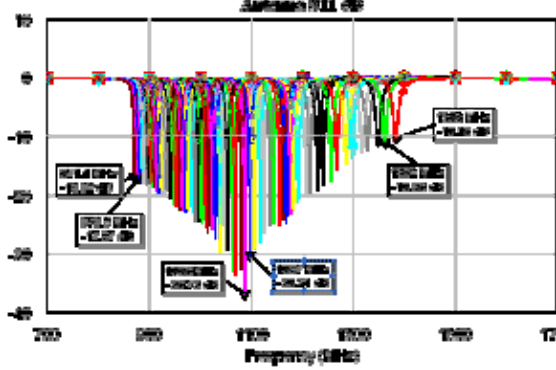




Tunable Antenna (TA) Demonstrator Measured Data



Demo TDCA tuning range – 3 to 11 pF




Low loss and highly linear tunable RF ICs enable antennas with:

- Tunability over at least one octave
- Sub-band operation
- Pre-select and spur suppression


- Impact on antenna volume (space) & efficiency by enabling:
 - Smaller volume & same efficiency, or
 - Same volume & higher efficiency

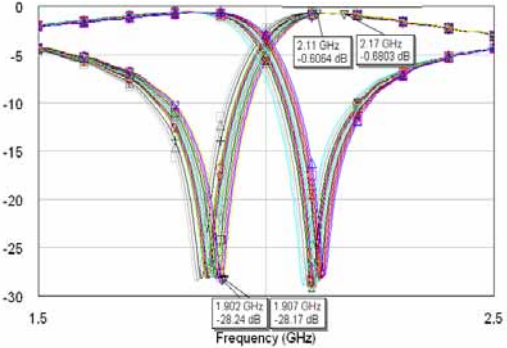
- Fairly omni-directional patterns
- Well-matched
- VSWR < 1.5:1 over passband

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Tunable Filters (TF): Notch Filter Demonstrator Measured Data



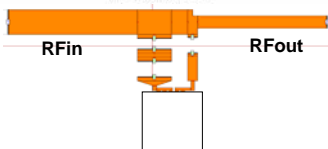


Components:

- SMD Air Core Inductor
- Standard FR-4
- Microstrip Line Based
- 50 Ohms Input/Output

Expected performance:

- Insertion Loss –0.7dB
- Return Loss < -15dB
- Rejection Level 23 dB
- High-band Tunability
- Variable Tx/Rx Spacing



Cooperative R&D Effort with Tier 1 Network Operator

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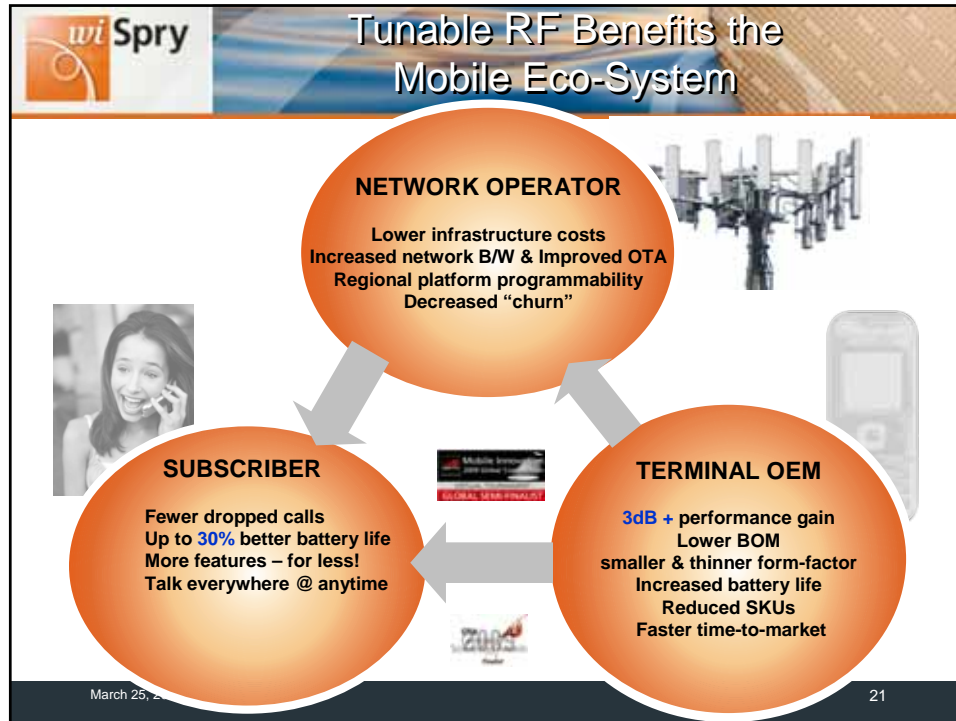
wiSpry WiSpry's Solution: A Completely Tunable RF Integration Platform

- Tunable Antenna (TA)
- Tunable LNA
- Tunable Impedance Matching (TIM)
- Rx & Tx Band-pass & Low-pass filters
- Tunable Duplexor (Band I, II, IV, V, VIII) (TDP)
- 3G PA Tuner (TPA) : LB & HB


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wiSpry 1st Generation Tunable Radio Front End

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-
- wi Spry** Integrated RF-MEMS Research Needs
- Sacrificial Materials and Release Techniques
 - Integration of "Good" RF Contact Metals (with Silicon)
 - Higher Frequency Mechanical Resonators
 - In-Line and End of Line Metrology
 - Wafer-Level Encapsulation and Hermeticity
 - Low Cost, High Performance Packaging Materials and Systems
 - Reliability Test and Acceleration Methods
 - Design Tools and Methodologies
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Tunable RF Technology: Competitive Landscape

Technology	CMOS MEMS	Fixed Passive	Silicon (SOI/SOS)	GaAs	MEMS	Ferro-Electric
Implementation Approach	Digital Variable Capacitors	Static L-C Network	Switched Passives	Switched Passives	Switched Passives	Analog Variable Capacitors
Tuning Range	Very High	None	Low	Low	Low	Medium
CMOS Integration Potential	Very High	Low	Very High	Low	Medium	Low
RF Performance	Very High	Low	Medium	Medium	Medium / High	High
Control	Digital / Open Loop	None	Digital	Digital	Digital	Analog / Closed Loop
Voltage	2.7 – 5.0	2.7 – 5.0	2.7 – 5.0	2.7 -5.0	2.7 - 50	1 – 28
Leader	WiSpry	Murata	Peregrine	Skyworks	TBD	Paratek
Other Players	NXP / EPCOS	EPCOS Handset OEMs	Infineon NXP EPCOS	RFMD Triquint MA-COM	RFMD XCOM Radant	AgileRF

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- 
- ### Summary
- 3G / 4G Mobile Terminals Require New Approaches to Integration of RF Front-End Functionality
 - Market Characteristics Make Adoption of New Technologies a Risky Proposition
 - Tunable RF Components Based on Integrated RF-CMOS MEMS Balance Risk with Benefits
 - Tunable Matching Networks, Antennas, and Filters Have Been Demonstrated Using a Digital Capacitor Array Architecture Implemented in 0.18um CMOS
 - Research and Development of a First Generation Multiband Tunable Radio Front-End is in Progress
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Questions?

Jeffrey L. Hilbert
President, COO & Founder, WiSpry, Inc.
20 Fairbanks, Suite 198, Irvine, CA U.S.A. 92618
+1 949-458-9477 x200
jeff.hilbert@wispry.com

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